

L Number	Hits	Search Text	DB	Time stamp
143	0	5866263.URPN.	USPAT	2003/04/04 13:47
144	0	5866263.URPN.	USPAT	2003/04/04 13:47
145	0	5866263.URPN.	USPAT	2003/04/04 13:47
146	4	("4427992" "4900646" "5250845" "5401536").PN.	USPAT	2003/04/04 13:47
-	1240	118/719.ccls.	USPAT; US-PGPUB	2003/04/04 10:45
-	54	"si" with "f" with (adsorp\$3 absorb\$3 adsorb\$3)	EPO; JPO; DERWENT	2003/04/03 16:06
-	50	"si" with "f" with (adsorp\$3 absorb\$3 adsorb\$3)	USPAT; US-PGPUB	2003/04/03 16:48
-	257	118/719.ccls. and (adsorp\$3 absorb\$3 adsorb\$3)	USPAT; US-PGPUB	2003/04/03 16:51
-	143	suzuki-tatsuya.in.	USPAT; US-PGPUB	2003/04/03 16:51
-	24	suzuki-tatsuya.in. and (wafer semiconductor substrate)	USPAT; US-PGPUB	2003/04/03 16:52
-	90	((206/832) or (206/833)).CCLS.	USPAT; US-PGPUB	2003/04/04 10:46
-	367	((206/832) or (206/833) or (206/710-712)).CCLS.	USPAT; US-PGPUB	2003/04/04 10:47
-	3	((((206/832) or (206/833) or (206/710-712)).CCLS.) and (silicon "si" "si-f" (silicon with fluorine)) not (((206/832) or (206/833) or (206/710-712)).CCLS.) and (silicon))	USPAT; US-PGPUB	2003/04/04 10:48
-	154	((((206/832) or (206/833) or (206/710-712)).CCLS.) and (silicon))	USPAT; US-PGPUB	2003/04/04 10:49
-	37332	((55/\$) or (96/\$)).CCLS.	USPAT; US-PGPUB	2003/04/04 10:50
-	1369	(55/\$.ccls. 96/\$.ccls.) and (silicon "si" "si-f" (silicon with fluorine))	USPAT; US-PGPUB	2003/04/04 10:52
-	203	(211/41.18).CCLS.	USPAT; US-PGPUB	2003/04/04 10:52
-	108	((211/41.18).CCLS.) and (silicon "si" "si-f" (silicon with fluorine))	USPAT; US-PGPUB	2003/04/04 10:52
-	397	118/500.ccls. and (silicon "si" "si-f" (silicon with fluorine))	USPAT; US-PGPUB	2003/04/04 10:53
-	0	118/500.ccls. and ("si-f" (silicon with fluorine))	USPAT; US-PGPUB	2003/04/04 10:55
-	8116	("si-f" (silicon with fluorine))	USPAT; US-PGPUB	2003/04/04 10:55
-	167	("si-f" (silicon with fluorine)) with (adsorb\$3 absorb\$3 adsorp\$3)	USPAT; US-PGPUB	2003/04/04 11:46
-	24	("si-f" (silicon with fluorine)) with (adsorb\$3 absorb\$3 adsorp\$3) with (carbon organic)	USPAT; US-PGPUB	2003/04/04 11:18
-	24	("si-f" (silicon with fluorine)) with (adsorb\$3 absorb\$3 adsorp\$3) with (carbon organic)	USPAT; US-PGPUB	2003/04/04 11:00
-	12	("si-f" (silicon with fluorine)) with (adsorb\$3 absorb\$3 adsorp\$3) with (carbon organic)	EPO; JPO; DERWENT	2003/04/04 11:05
-	70	("si-f" (silicon with fluorine)) with (adsorb\$3 absorb\$3 adsorp\$3)	EPO; JPO; DERWENT	2003/04/04 11:05
-	58	(("si-f" (silicon with fluorine)) with (adsorb\$3 absorb\$3 adsorp\$3)) not (("si-f" (silicon with fluorine)) with (adsorb\$3 absorb\$3 adsorp\$3) with (carbon organic))	EPO; JPO; DERWENT	2003/04/04 11:05
-	1	1993-059350.NRAN.	DERWENT	2003/04/04 11:10
-	1	("si-f") with (adsorb\$3 absorb\$3 adsorp\$3) with (carbon organic)	USPAT; US-PGPUB	2003/04/04 11:18
-	7	("si-f") with (adsorb\$3 absorb\$3 adsorp\$3)	USPAT; US-PGPUB	2003/04/04 11:20
-	3	("si-f") with (adsorb\$3 absorb\$3 adsorp\$3)	EPO; JPO; DERWENT	2003/04/04 11:20
-	1	2002-125242.NRAN.	DERWENT	2003/04/04 11:23
-	157	((206/832) or (206/833) or (206/710-712)).CCLS.) and (silicon "si" "si-f" (silicon with fluorine))	USPAT; US-PGPUB	2003/04/04 11:42

-	2	((206/832) or (206/833) or (206/710-712)).CCLS.) and ("si-f" (silicon with fluorine))	USPAT; US-PGPUB	2003/04/04 11:43
-	21	((55/\$) or (96/\$)).CCLS.) and ("si-f" (silicon with fluorine))	USPAT; US-PGPUB	2003/04/04 11:44